

# Colloidal Suspension **XA05**



- Anti-crystallization agent
- Easy to use
- For polishing applications
- High concentration
- Fast polishing process
- Cost efficiency

- **NX MET XA05** is used for polishing applications in the semiconductor and optoelectronic industries, as well as for metallographic super-finishing on a large range of materials. **XA05** is usually applied on **NX MET X100** polishing pads, or Eminess (Rodel) specialized polishing pads.  
**XA05** has exceptional performances, is easy to use due to its specific formula with anti-crystallization agent, and stays more on the polishing pad due to its special smoothness.

### **XA05 Product data:**

- Colloidal suspension
- Color: White
- pH: 9.6-10
- Boiling point: 100°C
- Grit size: 0.05µ
- Anti-crystallization agent
- Available in packaging from 1 to 25 Litres



12, allée Pin de St Clair - 38130 Echirolles France

Tel : +33 438 49 28 33 Fax : +33 438 49 27 85

[info@nxmet.com](mailto:info@nxmet.com) [www.nxmet.com](http://www.nxmet.com)

Distributed by

